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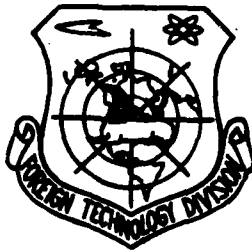
FOREIGN TECHNOLOGY DIVISION



EXPERIMENTAL INVESTIGATION OF THE DESTRUCTION OF THE
PROTECTIVE FILM BY A PULSED CO₂ LASER

by

Fang Huiying, Wang Cunkui, and Fu Yushou



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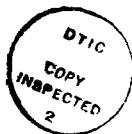
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EXPERIMENTAL INVESTIGATION OF THE DESTRUCTION OF ThF_4
PROTECTIVE FILM BY A PULSED CO_2 LASER

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(Mechanics Institute, Academia Sinica)

Currently, gold film reflectors are commonly used in high power 157
 CO_2 laser resonance chambers and focusing systems. Gold-film reflectors
are soft and easily soiled. They are easily damaged when cleaned and
scratch marks frequently appear, so that the optical qualities of the
reflector are affected.

In order to find a suitable protective film for gold-film reflectors,
the Heilongjiang Technical Physics Institute has plated gold-film re-
flectors with ThF_4 protective film. Experiments demonstrate that the 158
film possesses qualities that may overcome the defects mentioned above.

The optical films used in laser systems must possess not only
the quality of high mechanical scratch-proof and erosion-proof
capabilities, but also that of high laser-damage-prevention ability,
i.e., high damage threshold. This is very important for prolonging
laser lifetime and insuring good optical qualities.

Although the gold film's mechanical properties are enhanced by
the ThF_4 protective film, will the ability to prevent laser damage
of the gold film be maintained? This is a question concerning the
user. For this purpose, we have carried out some experimental
investigations on the laser-damage prevention ability of glass-based
and copper-based gold film reflectors after being plated with the
 ThF_4 protective film. In the experiment, samples are irradiated
with a CO_2 pulse laser of wave length of 10.6 micron (pulse
width is 0.6 microsecond) at 4 different energy densities: 1.2×10^6
 watt/cm^2 , $2.4 \times 10^6 \text{ W/cm}^2$, $2.7 \times 10^6 \text{ W/cm}^2$ and $35 \times 10^6 \text{ watt/cm}^2$. The
damages are observed and analysed microscopically.

1. EXPERIMENTAL SET-UP

A double-discharge CO₂ laser made in the Mechanics Institute is used in the experiment. The output energy is measured with a carbon energy meter. The output energy is focused with a germanium lens with a focal length of 100mm onto the sample (the germanium lens is coated with a transmission enhancing film). The beam spot shape is displayed by shining the laser beam on carbon paper. The spot area is determined with a microscope and the following formula is used to calculate the power density

$$I = \frac{E}{S\tau}$$

where E is the laser energy output, S - the beam spot area, and τ the pulse width. The experimental set up is shown in Figure 1.

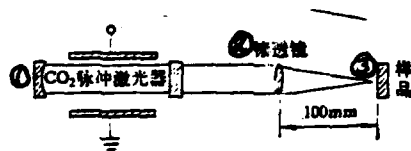


Figure 1. Diagram for the Experimental Set Up.

Key: 1--CO₂ pulse laser;
2--germanium lens; 3--sample.



Figure 2. K₈ glass Cr/Au
power density 1.2X10⁵ W/cm²
Enlarged 26 times.

Figure 3. K₈ glass Cr/Au/ThF₄
power density 1.2X10⁶ W/cm²
Enlarged 26 times.



TABLE 1. Tabulated Experimental Set Up

Base Material	Film Plated	Observed Result			
		$1.2 \times 10^6 \text{ W/cm}^2$	$2.4 \times 10^6 \text{ W/cm}^2$	$2.7 \times 10^6 \text{ W/cm}^2$	$3.5 \times 10^6 \text{ W/cm}^2$
K ₈ glass	Cr/Au	There is directly observable damage on the irradiated surface. The glass base is observed to have cracked under microscopic observation as shown in Figure 2.			
K ₈ glass	Cr/Au/ThF ₄	The ThF ₄ film is damaged on the irradiated surface. The film and the base are torn in layers as shown in Figure 3.			The degree of damaged increases but, is less than that, at $1.2 \times 10^6 \text{ W/cm}^2$ irradiation without the ThF ₄ protective film on the gold film, Figure 4.
Copper	Cr/Au	The film on the irradiated surface is not damaged.	The film on the irradiated surface is damaged. The base has cracked as shown in Figure 5.		
Copper	Cr/Au/ThF ₄	The film on the irradiated surface is not damaged.	The film on the irradiated surface has no directly observable damage.	The ThF ₄ film on the irradiated surface has begun to crack as shown in Figure 6.	The ThF ₄ film on the irradiated surface melts and wrinkles as shown in Figure 7.



Figure 4. K_8 glass Cr/Au/ThF₄ power density 35×10^6 W/cm² enlarged 20 times.

Figure 5. Copper base Cr/Au power density 2.4×10^6 W/cm² enlarged 20 times.



Figure 6. Copper base Cr/Au/ThF₄ power density 2.7×10^6 W/cm² enlarged 20 times.

Figure 7. K_8 glass Cr/Ag/ThF₄ power density 35×10^6 W/cm² enlarged 20 times.

2. EXPERIMENTAL RESULTS

From the above mentioned experimental results, we can see that there is a great difference in the degree of damage for mirrors of K_8 glass base plated respectively with Cr/Au and Cr/Au/ThF₄ films under 1.2×10^6 W/cm² power density irradiation. The reflector base without the ThF₄ film has already cracked while for the mirror with ThF₄ film, only the surface film is damaged. Even under the power

density of 3.5×10^7 W/cm², only the ThF₄ film starts to melt and crack for reflector with ThF₄ film.

The reflector with copper base plated with Cr/Au film under 2.4×10^6 W/cm² not only has the film damaged, but the base has also been observed to crack. However, at the same power density, the mirror plated with ThF₄ protective film has no directly observable damage. When the power density is 2.7×10^6 W/cm², the ThF₄ film begins to crack and flake. Only until we reach 3.5×10^7 W/cm² does the ThF₄ film start to melt and wrinkle.

3. CONCLUSION

(1) Experimental analysis indicates that the damages on the ThF₄ film are mainly the layering, cracking and melting due to thermal effect.

(2) Plating with the ThF₄ protective film improves not only the anti-mechanical scratch and anti-erosion ability of the gold film reflector, but also its ability to prevent laser damage.

(3) The experimental result indicates that the damage threshold of the ThF₄ protective film is between $10^6 - 10^7$ W/cm². This result agrees with the research result of ThF₄ protective film on silver-plated reflector in reference [1].

REFERENCES

- [1] Wang, V., et al, Laser induced Damage in optical materials, 183 (1972).

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